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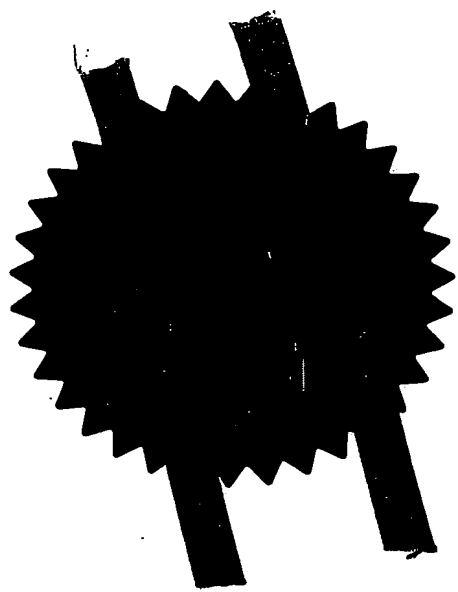
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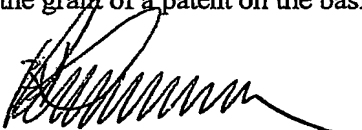
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DESCRIPTION

ACTIVE MATRIX DISPLAY DEVICES

This invention relates to an active matrix display device comprising first
5 and second substrates, electro-optical material disposed between the first and
second substrates, an array of display pixels comprising picture element
electrodes and associated switches carried together with sets of address
conductors on the first substrate, and a common electrode carried on the
second substrate, each picture element electrode together with an overlying
10 portion of the common electrode and the electro-optical material therebetween
defining a pixel, and drive means connected to the sets of address conductors
for applying drive signals to the array of pixels.

A common display device of this form is an AMLCD (active matrix liquid
crystal display). A typical example of such is described in US-A-5130829, the
15 contents of which are incorporated herein as reference material. In this device
an array of display pixels is provided, arranged in rows and columns, with each
pixel comprising an electro-optic cell, constituting a picture element, formed by
LC material sandwiched between a picture element electrode and part of a
counter electrode common to all pixels, and an associated thin film transistor
20 (TFT).

Display devices of this type are commonly used in monitors, TVs, lap-
top computers, PDAs, and mobile phones for example.

The TFTs of the pixels typically comprise amorphous silicon (a-Si) type
TFTs, or polycrystalline or microcrystalline silicon type TFTs formed on one
25 substrate of the device, usually of glass, together with a picture element
electrodes and sets of address conductors using well-known thin film
processing technology, typically involving the deposition and patterning of
various conducting, insulating, and semi-conducting layers using for example
CVD and photolithographic techniques. In the case of devices employing a-Si
30 TFTs, the driving circuitry, for example the row driver circuitry providing
selection (scanning) signals to a set of row address conductors, is usually
provided in the form of one or more silicon ICs. These can be provided on a

PCB separate to the display device substrates with, for example, a foil connector being used to connect the outputs of the ICs to respective address conductors. It is known also to mount the driver ICs on flexible foils connected to the address conductors. This can lead to cost reductions but a PCB is usually still employed to provide low resistance power lines and interconnections between the ICs. The driver ICs can instead be mounted directly on one substrate of the device, for example using COG (Chip On Glass) techniques, alongside one or more edges of the pixel array. When using polycrystalline or microcrystalline silicon TFTs for the pixels the driver circuitry may conveniently be integrated on the device's substrate carrying the active matrix circuit at one or more edges by forming the circuitry from thin film circuit elements and fabricating these elements simultaneously with the TFTs and other components of the pixel array from common deposited layers. In these two latter approaches, however, where the driver circuits are provided on a substrate of the device, problems can arise because of the higher resistances of connections on a glass substrate compared with those formed on a PCB. These problems can be particularly noticeable in comparatively large area AMLCDs, for example with a 20 inch diagonal or greater. Voltages supplied to certain components in the pixel array need to be well defined and stable other wise the quality of the images produced can be degraded. Connection resistances can affect such voltages, particularly in lines carrying larger currents, and may lead to visible artefacts in the display image. For example, vertical cross-talk effects, or longer range non-uniformity problems such as gate voltages changes to the address TFTs of the pixels causing flicker in the display image may result. Also, variation in reference voltage levels over the array can produce dark and light banding effects from the top to the bottom of the display image.

One particular feature which may be affected seriously in this way leading to unwanted display artefacts is the connection to pixel storage capacitor lines. Storage capacitors are commonly used in the pixels of an AMLCD to assist in maintaining a desired voltage across the picture element, and hence its display output, in the period following its addressing until it is

next addressed, generally corresponding to a frame period. The storage capacitor of a pixel is connected at its one side to the node between the TFT drain and the picture element electrode and at its other side to a reference potential which may be a row address conductor (gate line) associated with an adjacent (preceding or succeeding) row of pixels, or alternatively to an auxiliary conductor extending in the row direction and shared by all pixels in the same row. These auxiliary conductors are interconnected with one another and constitute a capacitor line. The introduction of resistances as low as, for example 5 to 10 ohms in the connection of this capacitor line can produce visible artefacts in the display image. An electrical connection formed on a glass substrate can typically result in a resistance of up to 100 ohms, and may thus be unacceptable.

According to the present invention there is provided an active matrix display device comprising first and second substrates, electro-optical material disposed between the first and second substrates, an array of display pixels comprising picture element electrodes and associated switches carried together with sets of address lines on the first substrate, and a common electrode carried on the second substrate, each picture element electrode together with an overlying portion of the common electrode and the electro-optical material therebetween defining a pixel, drive means connected to the sets of address conductors for applying drive signals to the array of pixels, the drive means comprising a drive circuit which is carried on the first substrate and includes conductor lines, the common electrode on the second substrate being connected electrically to at least one conductor line on the first substrate that provides a drive voltage for the common electrode, and the common electrode on the second substrate being utilised to provide electrical connection between the one conductor line and at least one other circuit element carried on the first substrate.

The drive circuit may be in the form of one or more ICs which are mounted on the first substrate, at a peripheral edge region outside the pixel array area or may comprise thin film circuitry integrated on the first substrate, again at a peripheral edge region, fabricated in known manner simultaneously

with the active matrix circuit associated with the pixels and from common deposited thin film layers. As a further alternative, the drive circuit may comprise one or more ICs mounted on a foil connector that is attached to, and supported by, the first substrate with its conductive tracks or lines being
5 connected to the circuitry carried directly on the substrate. This may be advantageous in enabling defective ICs to be replaced.

The use of the common electrode for electrical connection purposes in this manner is beneficial to avoiding the aforementioned connection resistance problems. The common electrode, normally comprising a transparent
10 electrically conductive material such as ITO, has a relatively low sheet resistance. Typically, the sheet resistance may be as low as a few ohms in the case where the ITO layer is backed by, and electrically contacts, a metallic black mask grid. Such a grid is present in most AMLCDs on the common electrode substrate, its primary function being to provide a light opaque border
15 around the individual picture elements to prevent optical cross-talk, and in some cases also to shield the pixel TFTs from light.

In an AMLCD the common electrode on one substrate is normally connected to a voltage bias source on the other substrate by means of one or more connections, so-called transfer contacts, formed for example by a silver
20 paste, and bridging the gap between the two substrates outside the display area, for example at the edge of one substrate. In a preferred embodiment of the invention, electrical connections between the common electrode on the second substrate and the conductor line on the first substrate and between the common electrode and an electrical contact area on the first substrate
25 associated with the other circuit element on the first substrate are provided in similar fashion, i.e using an electrically conductive material such as silver paste bridging the gap between the two substrates. Preferably, a plurality of spaced bridging connections between the two substrates are provided, for example arranged along opposing edges of the second substrate.

30 In a particular embodiment, the other circuit element comprises the storage capacitor line, and in this case a capacitor connection line connecting together the individual storage capacitor row line portions of the pixel rows

provided on the first substrate at one side of the array, for example adjacent an edge of the second substrate, or at each of two opposing sides of the array, and this connection line provides contact areas for the bridging connections. The facility for interconnection through the common electrode may also be
5 used to advantage in supplying other circuit elements on the active plate needing a corresponding voltage level.

Although AMLCDs are of particular interest, the device may use electro-optical materials other than liquid crystal crystal materials, such as electrophoretic or electrochromic materials for example.

10 An embodiment of active matrix display device, in particular an AMLCD, in accordance with the invention will now be described, by way of example, with reference to the accompanying schematic drawings, in which:-

Figure 1 shows a highly simplified cross-sectional view through part of an embodiment of AMLCD according to the invention;

15 Figure 2 illustrates the equivalent electrical circuit of the AMLCD of Figure 1;

Figure 3 is a plan view of an example AMLCD illustrating a known arrangement of certain components; and

20 Figure 4 is a plan view of the embodiment of AMLCD of Figure 1 illustrating certain features and components of the device.

It will be appreciated that the Figures are all merely schematic and are not drawn to scale. The same reference numbers are used throughout the figures to denote the same or similar parts.

Referring to Figure 1, the AMLCD is of generally conventional structure
25 having a matrix array of display pixels 8 and comprises first and second spaced substrates 10 and 12, typically of glass, between which a layer of liquid crystal material 14 is disposed. Only a relatively small part of the structure is shown in the Figure. The substrate 10, commonly referred to as the active plate, carries a row and column array of individual picture element electrodes
30 16 located adjacent respective intersections of crossing sets of row and column address conductors 18 and 20, only the column address conductors 20 being visible in the Figure. Each picture element electrode 16 is connected

to a respective switching device in the form of a TFT (thin film transistor) 22 (not shown in Figure 1) comprising an amorphous silicon or polycrystalline silicon type FET. The active matrix circuitry comprising the electrodes 16, address conductors 18, 20, and the TFTs 22 on the substrate 10 is covered by
5 a LC (liquid crystal) orientation layer 24.

The other substrate 12, commonly referred to as the passive plate, carries a continuous common, or counter, electrode 26 of transparent electrically conductive material, such as ITO, which is co-extensive with the array of picture element electrodes 16 and separated from the liquid crystal
10 layer 14 by an LC orientation layer 28. The common electrode 26 overlies a structure comprising an array of red, green and blue colour filter elements 30 aligned with respective electrodes 16 of the array of electrodes 16, and a light opaque black mask layer 31, in the form of a grid, portions of which extend between, and separate, individual colour filter elements 30 in known manner.

15 Each picture element electrode 16 together with a respective overlying portion of the common electrode 26, a respective colour filter element 30 and LC material therebetween defines a picture element which together with its associated TFT 22 constitutes a display pixel 8.

The two substrates 10 and 12 are maintained at a desired separation by
20 spacer elements (not shown) and sealed together around the periphery of the pixel array to contain the LC material by a seal 32 which also defines the boundary of the pixel array.

Referring now to Figure 2, which shows the equivalent circuit of the display device, each picture element electrode 16 is connected to the drain of
25 its associated TFT 22. The gates of the TFTs 22 of all the pixels 8 in the same row are connected to a respective row address conductor 18. The sources of the TFTs 22 of all the pixels 8 in the same column are connected to a respective column address conductor 20. Each display pixel 8 further includes, in known manner, a storage capacitor 35 connected at one side to
30 the node between its picture element electrode 16 and the TFT 22 and at its other side to a capacitor line 36 shared by all the pixels in the same row and provided in the form of an auxiliary row conductor extending in the row

direction. The capacitor row lines 36 associated with all pixel rows are connected together at both ends outside the area of the pixel array by capacitor connection lines 37 extending along opposing sides of the array. A suitable reference potential source is connected to these lines in operation of the device to provide a desired operating voltage bias to the storage capacitors.

The device is operated in generally conventional manner. Briefly, the sets of row and column address conductors 18 and 20 are respectively connected at their ends to row and column driver circuits 40 and 42. The pixel array is driven on a row at a time basis by means of the row driver circuit 40, comprising for example a digital shift register circuit, scanning the row address conductors 18 sequentially with a selection (gating) pulse signal so as to turn on the TFTs 22 of the pixels 8 of each row in turn in a respective row address period. The column driver circuit 42 supplies data (video) signals to the column address conductors 20 for each row of pixels in turn as appropriate and in synchronism with the row selection signals whereby the picture elements in each row are driven according the level of the applied data signal. Using one row at a time addressing, all TFTs 22 of the addressed row are switched on by the selection signal on the associated row conductor 18 for a period corresponding to the duration of that signal during which time the data signals are transferred from the column conductors 20 to charge up the picture element electrodes 16 and their associated storage capacitors 35. Upon termination of the selection signal, the TFTs of the row of pixels are turned off to isolate the picture elements from the column conductors 20 and ensuring the applied charge is stored in the picture elements and storage capacitors until the pixels are next addressed. All rows of pixels are addressed in turn in this manner in a frame period to produce a complete display image and repeatedly addressed in similar fashion in successive frame periods. Each picture element serves to modulate light passing through the picture element according to the applied data signal which determines its transmission characteristics. The device may be operable in a transmissive mode, in which the picture element electrodes 16 and the common electrode 26 are all formed

of transparent conductive material or in a reflective mode in which either the common electrode or the picture element electrodes are formed of light reflective material.

5 Timed operation of row driver circuit 40 is controlled by a timing and control circuit 44 which is also responsible for controlling the timing of the operation of the column driver circuit 42. The column driver circuit 42 is of any conventional kind and may be of analogue or digital type. In the former case it may, for example, comprise one or more shift register/sample and hold circuits with the timing and control circuit 44 supplying thereto video signal and timing
10 pulses, in synchronism with row scanning, to provide appropriate serial to parallel conversion.

During operation of the device, the common electrode 26 and the capacitor connection line 37 are held at a constant reference potential, for example, ground. Alternatively, and in accordance with known drive schemes,
15 the voltage on the electrode 26 may be modulated, in order to reduce the data signal voltage range necessary from the column driver circuit 42, with the voltage of the capacitor connection line 37 changing in corresponding fashion. In this case, the waveform applied to the row address conductors 18 is modified such that the non-selection, gate off, level is similarly modulated by a
20 corresponding amount to ensure that the address TFTs 22 of the pixels are held fully off in the intervals between selection and to avoid unwanted capacitive coupling effects.

From the foregoing, it will be appreciated that the general constructional and operational aspects of the device follow known practice and consequently
25 have not been described in great detail. Further details in these respects may be obtained from US-A-5130829 for example.

Figure 3 illustrates a known manner in which the row and column driver circuits 40 and 42 may be provided. In this, the circuits each comprise a set of individual silicon ICs, or chips, 80, 90, mounted on respective foil connectors
30 82 comprising a flexible film carrying conductive tracks which contact respective ones of the chip outputs. The substrate 12 is physically smaller than the substrate 10 and mounted to the substrate 10 so as to leave

peripheral edge regions of the substrate 10 exposed. The foil connectors 82 are bonded at their one side to these edge regions of the substrate 10, where the tracks electrically connect with respective extensions of the address conductors 18, 20, and at their other side to a PCB (printed circuit board), 84, 86 respectively for the set of row driver chips 80 and the set of column driver chips 90. The PCBs 84 and 86 each carry low resistance conductor lines associated with the set of chips such as power rails for voltage distribution which need to be low resistance to avoid voltage drops when currents flow in them, and timing signal lines. An electrical connection from the substrate 10 to the common electrode 26 carried on the second substrate 12 is achieved by one or more transfer contacts extending between the two substrates outside the seal line, and adjacent the edge of the substrate 12, as shown at 92 in Figure 1. In the Figure 3 arrangement two transfer contacts, 92, are provided at adjacent corners of the substrate 12. The transfer contacts typically comprise silver paste material contacting on the substrate 12 an extension of the common electrode and on the substrate 10 a conductive track, carrying the reference potential for the common electrode. A disadvantage of this kind of arrangement is that it can be expensive to implement. Moreover, it is not especially suited to producing a compact display device in view of the use of peripheral foil connectors and PCBs.

In an alternative known arrangement, the chips 80 constituting the row driver circuit are instead mounted directly on an edge region of the substrate 10 employing, for example, COG technology and using conductor tracks formed on the substrate 10 to provide the interconnection function of the PCB 84, thereby eliminating the need for that PCB. The chips 90 constituting the column driver circuit may be mounted on an edge of the substrate 10 in similar manner.

Figure 4 shows a plan schematic view of the embodiment of AMLCD according to the invention. In this particular example amorphous silicon type TFTs are used in the display pixels and the row and column driver circuits 40 and 42 each comprise a plurality of chips (ICs) arranged mutually spaced in a line. The chips 80 and 90 are mounted on respective edge regions of the

substrate 10 outside the pixel array area and the seal line and along respective adjacent sides of the pixel array. The chips are mounted on the substrate using any suitable known technique, for example COG, with individual output terminals of the chips electrically contacting respective extensions (not shown) of the sets of row and column address conductors 18 and 20 in known fashion. Electrically conductive tracks interconnecting the chips are formed on the surface of the substrate 10 extending along the edge regions which perform the same general function as the tracks of the PCBs in the above – described known arrangement in supplying power and timing signals, and, for the column driver chips 90 video data signals. Only one such track, indicated at 95, is shown in Figure 4 for simplicity, the track 95 extending alongside the line of row driver chips 80. A transfer contact 92 is provided adjacent each corner of the substrate 12 connecting the common electrode 26 at each of its four corners to driving voltage supply tracks 96 carried on the substrate 10, each transfer contact 92 overlying and electrically contacting a respective contact region of such a supply track.

Also arranged at spaced intervals alongside two opposing edges of the substrate 12 are additional bridging connections 100 extending between the two substrates 10 and 12 and at the edge of the substrate 12 in similar manner to the transfer contacts 92, there being a series of three additional contacts 100 provided on each side at opposing edges of the substrate 12 in the example illustrated although the number of such contacts can be varied. These bridging connections 100, formed similarly to the transfer contacts 92, for example of silver paste, define connection points between the substrates 10 and 12. At the substrate 12 they contact the common electrode 26, or an outwardly projecting extension thereof, and at the substrate 10 are arranged so as to overlie, and electrically contact, portions of the capacitor connection line 37 which for this purpose are arranged extending along the respective edge regions of the substrate 10 parallel to, and approximately beneath, the opposing edges of the substrate 12. In the illustrated embodiment, the same conductive track is used to constitute the capacitor connection line 37 and the track 96 supplying the drive voltage to the transfer contacts 92 on each side of

the array. The tracks 96/37 are connected, via a foil connector 82, to a column driver PCB 86' which carries the common electrode drive voltage generating circuit. Connections to external circuitry, providing for example power supply, video signals, etc, is made from the PCB 86', as shown at 102.

5 In this way, the common electrode 26 is utilised to provide, in addition to its usual function of serving as the second electrodes of the picture elements of the array, a supply function for elements of the active matrix circuit on the substrate 10, in this case in providing a required potential to the capacitor lines 36 and supplementing the connection lines 37 provided on the substrate 10.

10 This avoids problems which may be encountered in use due to nature of the lines 37 and their inherent resistance. Being formed from thin film conductive material on glass these lines inevitably possess low conductivity compared with, for example, the relatively much thicker conductive tracks of a PCB. As previously explained, it is especially important for producing a high quality

15 display image that the reference potential of the storage capacitors 35 be well defined and stable. The introduction of resistances as low as, for example, 5 ohms in the capacitor lines can result in highly visible unwanted display artefacts and connections on the glass substrate 10 can easily lead up to 100 ohms of connection resistance. The common electrode 26 typically has an

20 effective low sheet resistance, for example around just a few ohms in the case where the metallic black mask layer 31 is used which is in direct electrical contact with the ITO material of the common electrode 26. By virtue of the fact that the common electrode 26 is connected to a voltage bias source via the transfer contacts 92 the presence of the plurality of additional bridging

25 connections 100 enables a low resistance path to providing the required voltage bias to the storage capacitor lines 36 on the substrate 10.

 To assist in minimising the sheet resistance of the common electrode 26 and the connection resistance to the storage capacitor lines 26, the black mask layer 31 is preferably made of a low resistance alloy, such as aluminium,

30 copper or silver alloys.

 The same principle as described above to provide low resistance interconnect for the capacitor lines may be used for other components of the

circuitry on the substrate 10 where a bias potential equivalent to that of the common electrode is required. For example, such additional interconnects may be used for column driver circuit voltage level referencing purposes or in providing the appropriate, corresponding levels of the waveforms applied to the row address conductors 18' by the row driver circuit 40.

The use of the common electrode 26 in this way can eliminate the need to provide a separate PCB in association with the row driver circuitry, shown at 84 in Figure 3. The technique can also lead to a simplified, and physically smaller, PCB associated with the column driver circuitry, as shown at 86' in Figure 4 where the common electrode 26 is utilised as well to perform certain connection functions previously accomplished using PCB conductor tracks. This is achieved by a set of further additional bridging connections 100', similar to contacts 100, being used between the substrates 10 and 12 along the upper side edge of the substrate 12 to this end.

The additional bridging connections 100 and 100' are conveniently formed in the same manner and at the same time as the transfer contacts 92 using any suitable known techniques for forming such transfer contacts, for example as described in US-A-5625476, the contents of which are incorporated herein as reference material.

It is envisaged that the driver circuit ICs need not be mounted directly on the surface of the substrate 10. As an alternative, the driver ICs, for example the chips 80, may each be mounted on a foil that is carried on, and supported by, the substrate 10 at a peripheral region with the conductive tracks of the foil connecting to the circuitry on the substrate. This allows for easy replacement of the ICs should defects occur.

Although in the above described embodiment silicon ICs are used for the driver circuits, these circuits may instead be fully integrated on the substrate 10 using thin film component circuitry comprising TFTs, capacitors and interconnections, when using polycrystalline or microcrystalline silicon TFTs for the pixels 8. As is well known, row and/or column driver circuits can be readily fabricated using thin film technology similar to that used to produce the active matrix circuitry. Fabrication of the driver circuits simultaneously with

the active matrix circuitry, from common deposited thin film layers, leads to considerable cost savings.

From reading the present disclosure, other modifications will be apparent to persons skilled in the art. Such modifications may involve other features which are already known in the field of active matrix display devices and component parts therefor and which may be used instead of or in addition to features already described herein. Although claims have been formulated in this application to particular combinations of features, it should be understood that the scope of the disclosure of the present application also includes any novel feature or any novel combination of features disclosed herein either explicitly or implicitly or any generalisation thereof, whether or not it relates to the same invention as presently claimed in any claim and whether or not it mitigates any or all of the same technical problems as does the present invention. The applicants hereby give notice that new claims may be formulated to such features and/or combinations of such features during the prosecution of the present application or of any further application derived therefrom.

CLAIMS

1. An active matrix display device comprising first and second substrates, electro-optical material disposed between the first and second substrates, an array of display pixels comprising picture element electrodes and associated switches carried together with sets of address lines on the first substrate, and a common electrode carried on the second substrate, each picture element electrode together with an overlying portion of the common electrode and the electro-optical material therebetween defining a pixel, drive means connected to the sets of address conductors for applying drive signals to the array of pixels, the drive means comprising a drive circuit which is carried on the first substrate and includes conductor lines, the common electrode on the second substrate being connected electrically to at least one conductor line on the first substrate that provides a drive voltage for the common electrode, and the common electrode on the second substrate being utilised to provide electrical connection between the one conductor line and at least one other circuit element carried on the first substrate.

2. A device according to Claim 1, wherein the drive circuit comprises at least one integrated circuit mounted on the first substrate.

3. A device according to Claim 1, wherein the drive circuit comprises thin film circuit elements integrated on the first substrate.

4. A device according to any one of Claims 1 to 3, wherein the common electrode is connected to the at least one other circuit element via at least one connection element extending between the first and second substrates adjacent an edge of the second substrate.

5. A device according to any one of Claims 1 to 4, wherein the display pixels include storage capacitors which are connected at their one side to a capacitor connection line carried on the first substrate and wherein the

common electrode is utilised to provide electrical connection between the one conductor line and the capacitor connection line.

6. A device according to Claim 5, wherein the capacitor connection
5 line extends on the first substrate adjacent one edge of the second substrate
and connects together at one side of the array a plurality of capacitor
connection line row portions, each row portion being connected to the storage
capacitors of a respective row of pixels, and wherein the common electrode is
connected electrically with the capacitor connection line at spaced locations
10 along that edge of the second substrate.

7. A device according to Claim 6, wherein the capacitor connection
line also extends on the first substrate adjacent an opposing edge of the
second substrate and connects together the plurality of capacitor connection
15 row portions at the opposing side of the array, and wherein the common
electrode is connected with the capacitor connection line at spaced locations
along the opposing edge of the second substrate.

8. A device according to Claim 6 or 7, wherein the common
20 electrode is connected to the capacitor connection line via bridging
connections extending between the first and second substrates arranged
along a substantial part of the length of the edge of the second substrate.

9. A device according to Claim 8, wherein the bridging connections
25 comprise conductive material disposed between the two substrates adjacent
the edge of the second substrate.

10. A device according to any one of the preceding claims, wherein
the common electrode is connected to the at least one conductive line on the
30 first substrate via at least one bridging connection comprising conductive
material disposed between the two substrates adjacent an edge of the second
substrate.

11. A device according to Claim 10, wherein the common electrode is connected to the at least one conductive line via a plurality of bridging connections arranged adjacent corners of the second substrate.

5

12. A device according to any one of the preceding claims, wherein in the second substrate carries a metallic black mask layer adjacent to, and in electrical contact with, the common electrode.

10

13. A device according to any one of the preceding claims, wherein the electro-optical material comprises liquid crystal material.

Abstract

ACTIVE MATRIX DISPLAY DEVICES

5 In an active matrix display device, particularly an AMLCD, having an array of display pixels (8) and comprising pixel electrodes (16), associated switches (22), and address lines (18, 20) carried on a first substrate (10), a common electrode (26) carried on a second substrate (12), a drive circuit (40, 80) carried on the first substrate (10) including at least one conductor line (96) providing a drive voltage for the common electrode (26) and to which the
10 common electrode (26) is connected (92), the common electrode (26) on the second substrate is utilised to provide also electrical connection between the one conductor line (96) and at least one other circuit element (37) carried on the first substrate (10). The use of the common electrode in this way assists in
15 avoiding problems due to resistances of connections formed on the first substrate. The connection to a storage capacitor line (37, 36) may benefit especially. The common electrode (26) may be connected to the circuit elements on the first substrate via contact material (92, 100) extending across the gap between the two substrates.

20

Fig 4

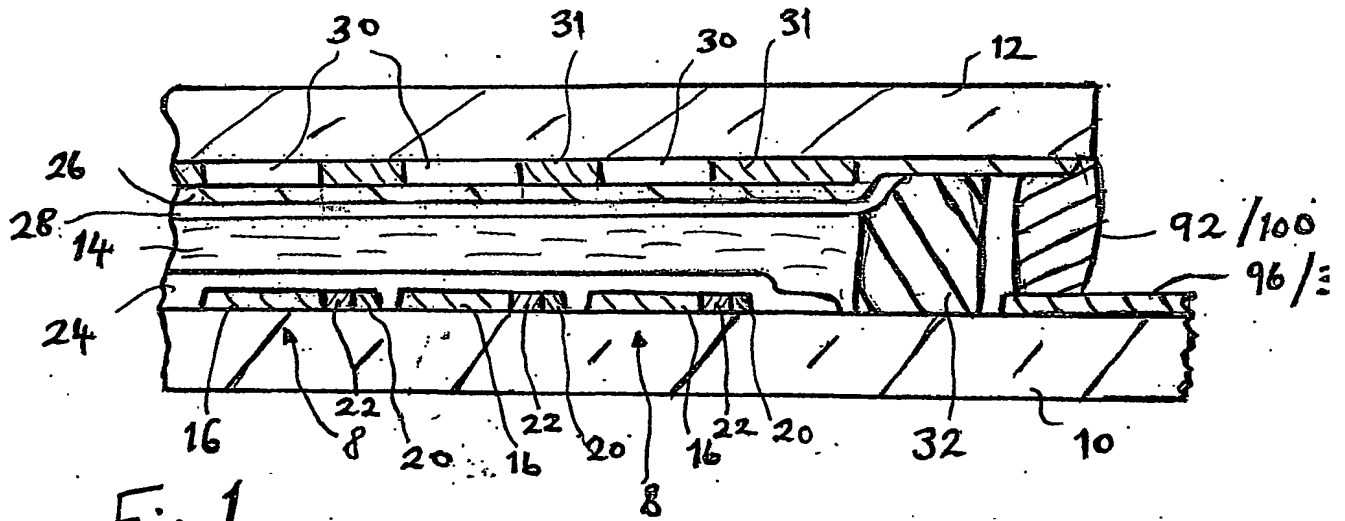


Fig.1.

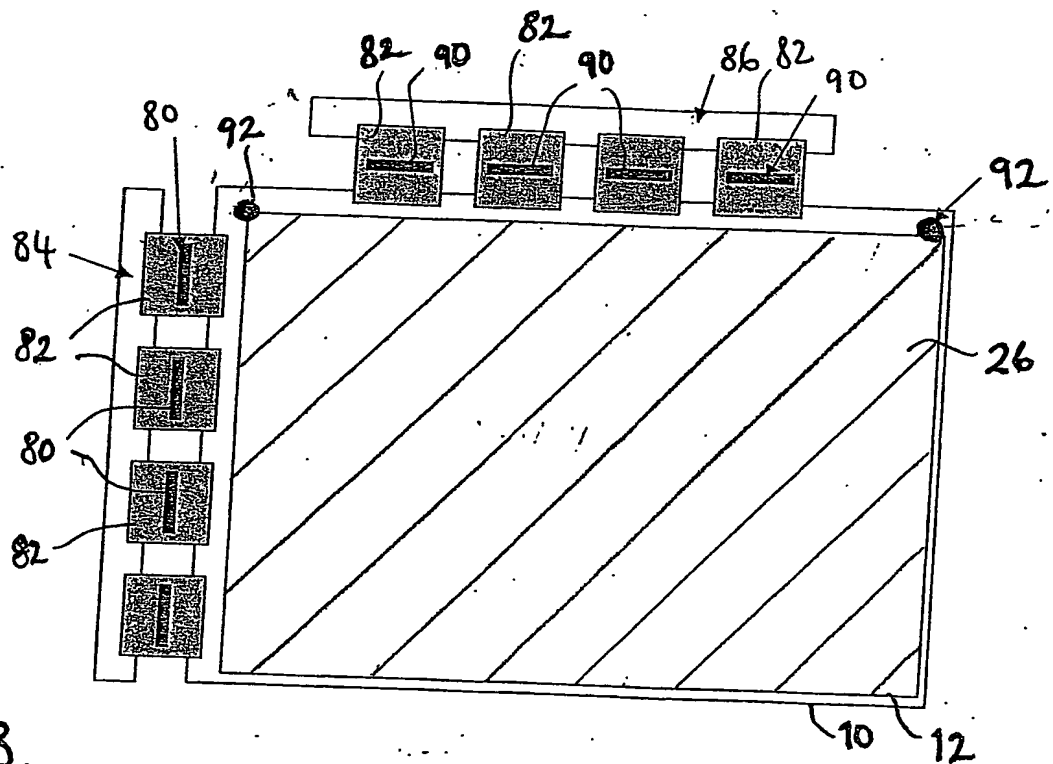


Fig.3.

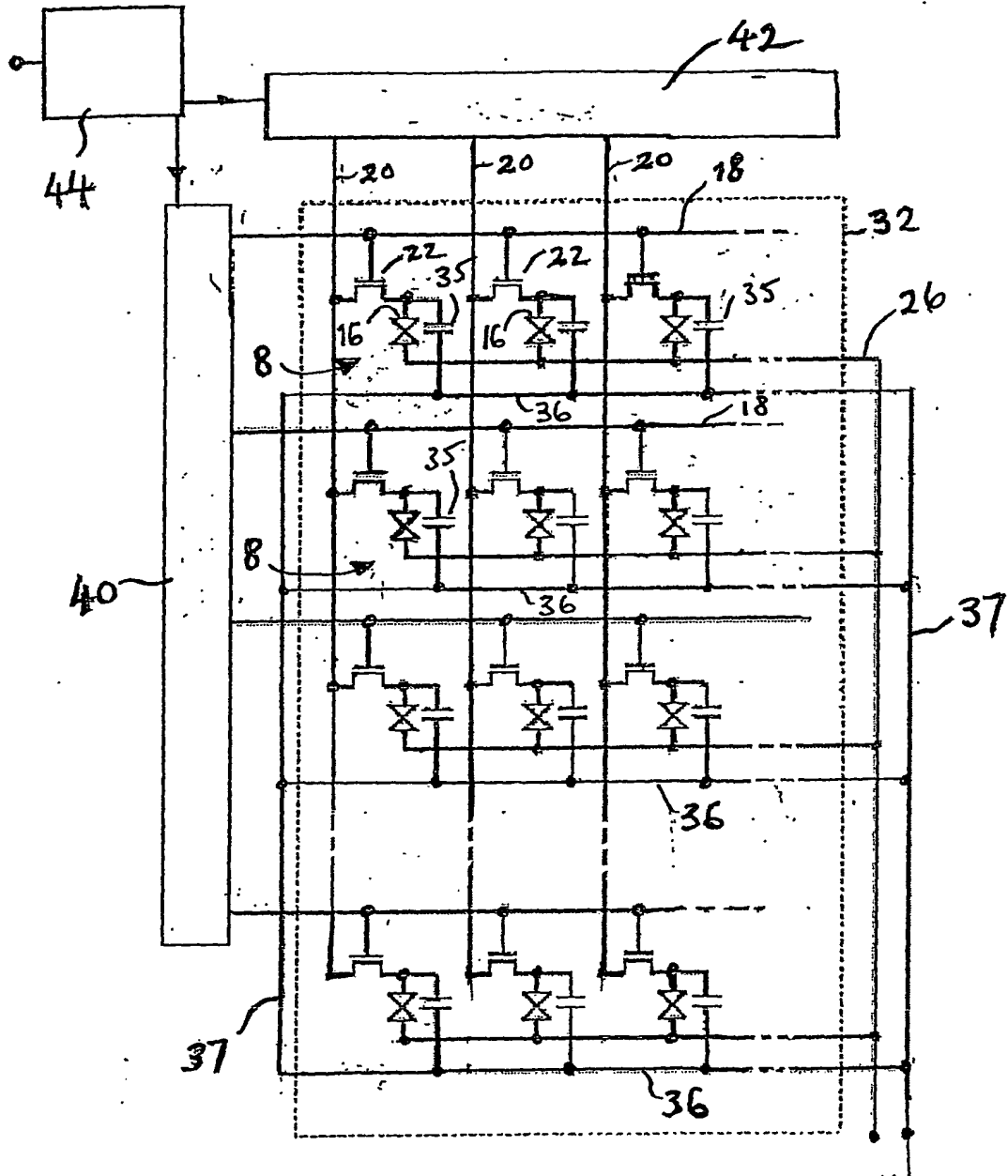


Fig. 2.

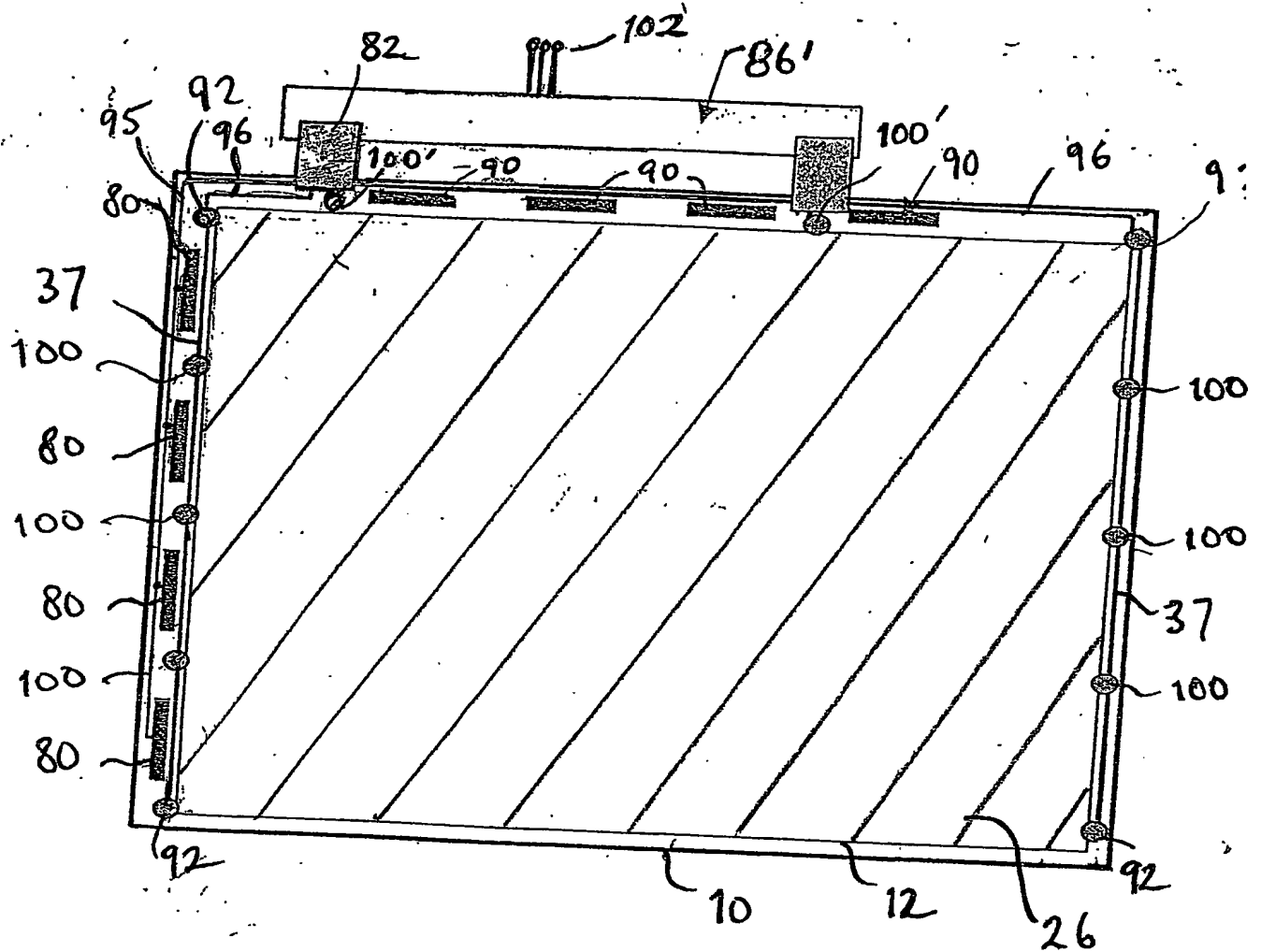


Fig. 4.

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